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Variance and skewness of the multiplication gain distribution in uniform avalanche diodes

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We derived exact analytical expressions for the variance, the third central moment, and the skewness of the multiplication gain distribution in uniform avalanche structures. The model assumes Poissonianity and locality of the ionization process and is valid for arbitrary values of the electron and hole ionization coefficients, α and β , respectively, as functions of the space coordinate. Expressions are also provided for the particular case where the ionization coefficients are related by a constant ratio $k = \beta/\alpha$. The skewness is found to be always positive and greater than 2, indicating statistically relevant. Finally, the implications for spectral measurements of ionizing radiation are reviewed.

KEYWORDS

avalanche diode, LGAD, multiplication gain variance, multiplication gain skewness, energy resolution

1 Introduction

The stochastic nature of the impact ionization mechanism due to energetic charge carriers in avalanche semiconductor devices [1] causes the overall multiplication gain to be distributed according to a non-trivial probability density function, with important implications on the behavior of the noise. The noise mechanisms and their impacts on the overall device properties have been the subject of a remarkable series of studies since the 1960s (e.g., [2] among the firsts). This was partly due to the versatility of this class of devices, making them suitable for a vast range of applications, and partly due to the complexity of the description of the avalanche multiplication phenomenon *per se*.

For instance, [3] McIntyre derived an expression for the noise spectral density due to the self-multiplication of the leakage current and possibly of the photo-generated and thermal-generated currents in uniform (i.e., one-dimensional) avalanche diodes as a function of the electron and hole impact ionization coefficients α and β , respectively, functions of the space coordinate x. The model was developed under a set of assumptions, which are worth mentioning as they will be maintained throughout this work: i) the noise of the multiplied carrier streams is shot noise, i.e., follows Poisson statistics, and ii) the ionization coefficients are assumed to be functions of the electric field only, neglecting the history of the charge carrier momentum build-up and qualifying the theory as "local," in contrast to more physically accurate, but less handy, non-local models such as those employed by [4]. These two characteristics qualify this theory as "continuous," retaining validity as an "asymptotic" theory [5]. It is the case that the number of possible independent collisions within the avalanche region can become so large that it justifies the use of continuous ionization rates per unit length $\alpha(x)$ and $\beta(x)$. In contrast, other theories such as those proposed by [5, 6] treat the ionization process as a finite sequence of independent Bernoulli trials, which were

found to better describe the behavior of devices with a very thin avalanche region where the number of possible collisions is small. From the excess noise spectral density derived in a condition of stationarity [3], it is allowed to extract the variance of the multiplication gain by virtue of Burgess' theorem on the variance of a random sum [7] (see Appendix 2) and Milatz's theorem [8] (a special case of MacDonald's theorem [9]). The procedure is well explained by [10, 11]. This means that means, with $S_{I_{in}}$ being the noise spectral density of the output (multiplied) current, and \mathcal{M} being the multiplication gain distribution, the following relationship holds

$$S_{I_{out}} = S_{I_{in}} \mathbb{E}[\mathcal{M}]^2 F, \qquad (1)$$

$$= S_{I_{in}} \mathbb{E}[\mathcal{M}]^2 + 2q \mathbb{E}[I_{in}] \mathbb{V}[\mathcal{M}], \qquad (2)$$

where *F* is the noise excess factor, *q* is the electric charge, $\mathbb{E}[\cdot]$ is the mean value operator, and $\mathbb{V}[\cdot]$ is the variance operator. Since $S_{I_{in}} = 2q\mathbb{E}[I_{in}]$, it follows that

$$\mathbb{V}[\mathcal{M}] = \mathbb{E}[\mathcal{M}]^2 (F - 1).$$
(3)

The knowledge of the variance of the multiplication gain can be of particular interest in spectral resolution applications [12] as it directly contributes to the uncertainty in energy measurements pertaining to single pulses. It has to be noted, however, that the statistical moments of \mathcal{M} do not end with the second moment (i.e., the variance). This means that both the stationary current noise and single pulse noise can depart, to some degree, from a typical, symmetric, normal distribution, with potential implications for the interpretation and impact of the multiplication noise. For example, information on the skewness of single pulses was used to improve the characterization of silicon photomultiplier (SiPM) devices [13], while experimental sources of evidence on the skewness and even higher moments in current fluctuations in single photon avalanche diodes (SPADs), supported by statistical thermodynamic considerations on non-linear devices, are described in [14, 15] and references therein. The expression for the probability distribution of the number of final (after multiplication) carriers as a function of the number of initial carriers (and therefore of the multiplication gain) was already derived by [16-18]. As highlighted by [16], it is exemplary that the probability distribution generated by one single initial carrier has a maximum in correspondence with one final carrier for any value of the mean multiplication gain. In principle, the computation of the statistical moment should then be possible, but apart from the difficulty of coming to an analytical solution given by the complexity of the expressions, all the aforementioned studies are limited by the assumption of linear dependency of the ionization coefficients $\beta = k\alpha$.

To overcome this limitation, in this work, we present an analytical derivation of the third central moment and the skewness of the multiplication gain distribution for arbitrary α and β . The assumptions of Poissonianity and the locality of the ionization process are maintained. The model relies on the property of additivity of the central moments for a sum of random variables up to the third degree and the composition rules for the moment of a random sum. This originates an integral equation similar to the equation for the mean multiplication gain M(x) presented by [3], which is briefly reported for the sake of readability. In addition, for

completeness, we present the derivation of the variance using the same strategy, showing the coincidence with the result obtained in Equation 3.

Apart from a purely theoretical interest, knowledge of the skewness of the multiplication gain can contribute to better modeling of avalanche structures and better understanding and interpretation of their behavior [12, 19]. For example, it is worthwhile to mention the increasing interest in avalanche devices in fields beyond optical photon science, such as the case of low-gain avalanche diodes (LGADs) with energy-resolving capabilities in high-energy physics with tracking and timing applications [20] and soft X-ray synchrotron applications [21]. In this context, we provide a simple model for the evaluation of the impact of the skewness of the multiplication gain on spectral measurements of ionizing radiation.

2 Materials and methods

The investigated avalanche structure consists of an np junction with a depletion layer extending from x = 0 to x = w. In this framework, electrons will drift toward x = 0, while holes will drift toward x = w. The ionization coefficients for electrons and holes are indicated with α and β , respectively, and they represent the electron-hole pair generation rates due to impact ionization. They are, in general, functions of the local electric field and, therefore, of the position x, but for simplicity of notation, we omit these.

2.1 Mean multiplication gain

To facilitate reading, we provide a brief summary of the derivation of the mean multiplication gain as a function of x, corresponding to the initial position of the electron-hole pair that starts the avalanche, as presented by [3]. Some notable equalities are also mentioned as they will be used in the remainder of this study. Let us indicate the mean multiplication gain with $M(x) = \mathbb{E}[\mathcal{M}(x)]$. As the electron travels each displacement element dx toward the collecting electrode, it will generate, on average, βdx electron-hole pairs. Similarly, a hole will generate, on average, βdx electron-hole pairs. The secondary pairs will, in turn, start ionization chains according to their starting position x', and therefore, they will propagate as M(x'). This leads us to the following linear integral equation of the

$$M(x) = 1 + \int_{0}^{x} \alpha M(x') dx' + \int_{x}^{w} \beta M(x') dx'.$$
 (4)

After differentiating, we obtain

$$\frac{\mathrm{d}M(x)}{\mathrm{d}x} = (\alpha - \beta)M(x), \tag{5}$$

whose solutions are

$$M(x) = M(0)e^{\int_0^{\pi} (\alpha - \beta) dx'},$$
(6)

$$= M(w)e^{-\int_{x}^{w} (\alpha-\beta)dx'}.$$
 (7)

By substituting Equation 7 into Equation 4, for x = w, we obtain

$$M(w) = \frac{1}{1 - \int_0^w \alpha e^{-\int_x^w (\alpha - \beta) \mathrm{d}x'} \mathrm{d}x},$$
(8)

and analogously, substituting Equation 6 into Equation 4 for x = 0, we obtain

$$M(0) = \frac{1}{1 - \int_0^w \beta e^{\int_0^x (\alpha - \beta) dx'} dx}.$$
 (9)

Thus,

$$M(x) = \frac{e^{-\int_{x}^{w} (\alpha - \beta) \mathrm{d}x'}}{1 - \int_{0}^{w} \alpha e^{-\int_{x}^{w} (\alpha - \beta) \mathrm{d}x'} \mathrm{d}x}.$$
 (10)

Two particular cases are given as follows:

Case $\alpha = \beta$.

If the electron and hole ionization coefficients are equal, M is no longer a function of x but reduces to a constant:

$$M = \frac{1}{1 - \int_0^w \alpha \mathrm{d}x}.$$
 (11)

Case $\beta = k\alpha$

If the electron and hole ionization coefficients are related by a fixed ratio k, from Equation 4, it follows the notable equality:

$$M(0) - 1 = k[M(w) - 1].$$
(12)

2.2 Variance of the multiplication gain

Let us indicate the variance of the multiplication gain by $V(x) = \mathbb{E}[(\mathcal{M}(x) - \mathbb{E}[\mathcal{M}(x)])^2] = \mathbb{V}[\mathcal{M}(x)],$ and let us consider again an initial electron-hole pair starting at position x. Generalizing from the previous case, each primary carrier traversing a displacement element dx toward the corresponding collecting electrodes will generate a random number of secondary electron-hole pairs, which are assumed to be distributed according to Poisson statistics. Each of these secondary carriers will, in turn, initiate an ionization chain according to their starting position x' and propagate according to the gain distribution $\mathcal{M}(x')$. This behavior corresponds to random sum, i.e., to the sum of a random number of identically and independently distributed variables. Under the assumption of independence of the ionization events, the variances generated by each carrier at each displacement element dx can be summed up. The composition rule for the variance of a random sum of independent events, also known as Burgess' theorem, is reported in Appendix 2. In particular, for an electron traversing a displacement element dx at position x', the quantities in Equation B2 for the resulting variance are identified as follows: $\mathbb{E}[k]$ corresponds to the average number of electron-hole pairs generated by the traveling electron αdx ; $\mathbb{V}[k]$ corresponds to its variance, which, under the assumption of Poissonianity of the ionization process, coincides with the average number αdx ; $\mathbb{E}[X_0]$

corresponds to the mean multiplication gain M(x'); and $\mathbb{V}[X_0]$ corresponds to the variance of the multiplication gain V(x'). Therefore, the variance element propagates as $\alpha dx [M(x')^2 + V(x')]$. The same reasoning applies to holes, replacing α with β .

The total variance V(x) originated from the initial electron-hole pair starting at position x obeys the following integral equation:

$$V(x) = \int_{0}^{x} \alpha \Big[M(x')^{2} + V(x') \Big] dx' + \int_{x}^{w} \beta \Big[M(x')^{2} + V(x') \Big] dx'.$$
(13)

After differentiating, we obtain

$$\frac{\mathrm{d}V(x)}{\mathrm{d}x} = \left(\alpha - \beta\right) \left[M(x)^2 + V(x)\right],\tag{14}$$

which is a first-order ordinary differential equation of the first order with variable coefficients in the form:

$$\frac{\mathrm{d}V(x)}{\mathrm{d}x} = a(x)V(x) + b(x),\tag{15}$$

where $a(x) = (\alpha - \beta)$ and $b(x) = (\alpha - \beta)M(x)^2$.

The general solution is

$$V(x) = V(0)e^{A(x)} + e^{A(x)} \int_0^x e^{-A(x')} b(x') dx',$$
 (16)

where the function $A(x) = \int_0^x a(x') dx'$ is a particular antiderivative of the function a(x).

The initial value V(0) can be derived by substituting Equation 16 into Equation 13 for x = w, which leads to

$$V(0) = \frac{\int_{0}^{w} \alpha \left[M(x)^{2} + e^{A(x)} \int_{0}^{x} e^{-A(x')} b(x') dx' \right] dx - e^{A(w)} \int_{0}^{w} e^{-A(x)} b(x) dx}{e^{A(w)} - \int_{0}^{w} \alpha e^{A(x)} dx}.$$
(17)

The components of Equations 16, 17 can be elaborated as follows: for instance, from Equation 6, it holds that

$$e^{A(x)} = \frac{M(x)}{M(0)},$$
(18)

which obviously implies that

$$e^{A(w)} = \frac{M(w)}{M(0)}.$$
 (19)

Then, using Equation 4, for x = w, we found that

$$\int_{0}^{w} \alpha M(x) dx = M(w) - 1,$$
 (20)

which is needed to solve the following equality:

$$-\int_{0}^{w} \alpha e^{A(x)} dx = -\frac{1}{M(0)} \int_{0}^{w} \alpha M(x) dx = \frac{1 - M(w)}{M(0)}.$$
 (21)

Furthermore, using Equations 5, 18, we can write that

$$e^{A(x)} \int_{0}^{x} e^{-A(x')} b(x') dx' = \frac{M(x)}{M(0)} \int_{0}^{x} \frac{M(0)}{M(x')} (\alpha - \beta) M(x')^{2} dx',$$
(22)

$$= M(x) \int_{0}^{x} \frac{\mathrm{d}M(x')}{\mathrm{d}x'} \mathrm{d}x', \qquad (23)$$

$$= M(x)[M(x) - M(0)].$$
(24)

The initial value V(0) can then be rewritten as

$$V(0) = M(0) \\ \times \left\{ \int_{0}^{w} \alpha [2M(x)^{2} - M(x)M(0)] dx - M(w)^{2} + M(w)M(0) \right\},$$
(25)

which, using Equation 20, can be simplified into

$$V(0) = M(0) \left\{ 2 \int_{0}^{w} \alpha M(x)^{2} dx + M(0) [1 - M(w)] - M(w)^{2} + M(w) M(0) \right\}.$$
(26)

By substituting Equation 26 into Equation 16 and simplifying, we finally obtain

$$V(x) = 2M(x) \int_{0}^{w} \alpha M(x)^{2} dx + M(x)^{2} - M(x)M(w)^{2}.$$
 (27)

Now, this formulation is consistent with the excess noise factor computed by [3] in Equation 13 (minus the term $M(x)^2$, as expected from Equation 3) if the quantities related to the current injected at the contacts are null, i.e., $I_p(0) = I_n(w) = 0$, and the quantity related to the generation rate per unit length corresponds to a Dirac's delta distribution function: $g(x') = 1\delta(x - x')$.

Case $\alpha = \beta$

Like the mean M, its variance V is no longer a function of x, and Equation 27 is reduced to

$$V = M^3 - M^2.$$
 (28)

Case $\beta = k\alpha^1$

The integral $2 \int_0^w \alpha M(x)^2 dx$ can be performed in virtue of Equation 5, and it yields

$$2\int_{0}^{w} \alpha M(x)^{2} dx = 2\int_{0}^{w} \frac{dM(x)}{dx} \frac{1}{1-k} M(x) dx,$$
 (29)

$$=\frac{M(w)^2 - M(0)^2}{1 - k}.$$
 (30)

Therefore,

$$V(x) = M(x)\frac{M(w)^{2} - M(0)^{2}}{1 - k} + M(x)^{2} - M(x)M(w)^{2}.$$
 (31)

Finally, using Equation 12, we can express the variance resulting from the injection of holes only (x = 0) or electrons only (x = w) as a function of their respective mean multiplication gain:

$$V(0) = M(0)^{3} \left[1 + \frac{1-k}{k} \left(\frac{M(0)-1}{M(0)} \right)^{2} \right] - M(0)^{2}, \quad (32)$$

$$V(w) = M(w)^{3} \left[1 - (1-k) \left(\frac{M(w) - 1}{M(w)} \right)^{2} \right] - M(w)^{2}.$$
 (33)

2.3 Skewness of the multiplication gain

The skewness (or third standardized moment) of the multiplication gain is defined as

$$S(x) = \frac{T(x)}{V(x)^{3/2}},$$
(34)

where T(x) represents the third central moment T(x) = $\mathbb{E}[(\mathcal{M}(x) - \mathbb{E}[\mathcal{M}(x)])^3] = \mathbb{T}[\mathcal{M}(x)]$ and $\mathbb{T}[\cdot]$ indicates the third central moment operator. Since the variance was already addressed in the previous section, it now need to determine T(x). Its derivation initiates from the same premises as for the variance, i.e., by recognizing that the amount of electron-hole pairs generated via impact ionization by a carrier at position x' and traveling toward the corresponding collecting electrode by a displacement element dx corresponds to a random sum. Under the assumption of independence of ionization events, the third central moments generated at each displacement element can be summed.² The composition rule for the third central moment of a random sum is reported in Appendix 3. In particular, for an electron traversing a displacement element dx at position x', the quantities in Equation B3 for the resulting third central moment are identified as follows: $\mathbb{E}[k]$ corresponds to the average number of electron-hole pairs generated by the traveling electron αdx ; $\mathbb{V}[k]$ corresponds to its variance αdx ; $\mathbb{T}[k]$ corresponds to its third central moment, which, under the assumption of Poissonianity of the ionization process, coincides again with αdx ; $\mathbb{E}[X_0]$ corresponds to the mean multiplication gain M(x'); $\mathbb{V}[X_0]$ corresponds to the variance of the multiplication gain V(x'); and $\mathbb{T}[X_0]$ corresponds to the third central moment of the multiplication gain T(x'). Therefore, the third central moment element propagates as $\alpha dx [M(x')^3 + 3M(x')V(x') + T(x')].$ The same reasoning applies to holes, replacing α with β .

The total third central moment T(x) originated from an initial electron-hole pair starting at position x obeys the following integral equation:

$$T(x) = \int_{0}^{x} \alpha \Big[M(x')^{3} + 3M(x')V(x') + T(x') \Big] dx' + \int_{x}^{w} \beta \Big[M(x')^{3} + 3M(x')V(x') + T(x') \Big] dx',$$
(35)

which, after differentiation, yields

$$\frac{\mathrm{d}T(x)}{\mathrm{d}x} = \left(\alpha - \beta\right) \left[M(x)^3 + 3M(x)V(x) + T(x)\right]. \tag{36}$$

Like in the case of Equation 14, the general solution of Equation 36 is given in the form

¹ Please refer to [16] for a critical review of this approximation to the purpose of the excess noise factor in the noise spectral density of current fluctuations.

² The property of additivity of the central moments of the sum independent stochastic variable holds up to the third degree, so the method presented in the text cannot be extended to higher moments.

$$T(x) = T(0)e^{A(x)} + e^{A(x)} \int_0^x e^{-A(x')} b(x') dx', \qquad (37)$$

where the function $A(x) = \int_0^x a(x')dx'$ is a particular antiderivative of functions $a(x) = (\alpha - \beta)$ and $b(x) = (\alpha - \beta)M(x)[M(x)^2 + 3V(x)]$.

The initial value T(0) can be obtained by substituting Equation 37 into Equation 35 with x = w, leading to

T(0)

$$=\frac{\int_{0}^{w} \alpha \Big[M(x)^{3} + 3M(x)V(x) + e^{A(x)} \int_{0}^{x} e^{-A(x')} b(x') dx' \Big] dx - e^{A(w)} \int_{0}^{w} e^{-A(x)} b(x) dx}{e^{A(w)} - \int_{0}^{w} \alpha e^{A(x)} dx}$$
(38)

The components of Equations 37, 38 can be elaborated further. For instance, we observe that

$$e^{A(x)} \int_{0}^{x} e^{-A(x')} b(x') dx' = \frac{M(x)}{M(0)} \int_{0}^{x} \frac{M(0)}{M(x')} (\alpha - \beta) M(x') \\ \times \left[M(x')^{2} + 3V(x') \right] dx',$$
(39)

$$= M(x) \int_0^x (\alpha - \beta) \left[M(x')^2 + 3V(x') \right] \mathrm{d}x', \tag{40}$$

$$= M(x) \int_{0}^{x} (\alpha - \beta) 3 \left[M(x')^{2} + V(x') \right] dx' -M(x) \int_{0}^{x} (\alpha - \beta) 2 M(x')^{2} dx',$$
(41)

$$= 3M(x)[V(x) - V(0)] - M(x)[M(x)^{2} - M(0)^{2}], \qquad (42)$$

where in the last passage, we used Equation 14. Then, using Equations 18, 21, we notice that the denominator of Equation 38 is reduced to 1/M(0). Thus, T(0) can be rewritten as

$$T(0) = M(0) \left[6 \int_{0}^{w} \alpha M(x) V(x) dx + M(w)^{3} - 3M(w) V(w) + 3V(0) - M(0)^{2} \right].$$
(43)

By substituting Equation 43 into Equation 37 and simplifying, we finally obtain

$$T(x) = 6M(x) \int_{0}^{w} \alpha M(x) V(x) dx + 3M(x) V(x) + M(x) M(w)^{3} - 3M(x) M(w) V(w) - M(x)^{3}.$$
 (44)

Case $\alpha = \beta$

Like the mean M and the variance V, the third moment T is also no longer a function of x, and thus, Equation 44 reduces to

$$T = 3M^5 - 5M^4 + 2M^3.$$
(45)

Case $\beta = k\alpha$

The term $\int_0^w \alpha M(x)V(x)dx$ in Equation 44 can be integrated in virtue of Equations 5, 31, which yields

$$\int_{0}^{w} \alpha M(x)V(x)dx = \frac{\left[M(w)^{2} - M(0)^{2}\right]^{2}}{2(1-k)^{2}} + \frac{M(w)^{3} - M(0)^{3}}{3(1-k)} - \frac{M(w)^{2}\left[M(w)^{2} - M(0)^{2}\right]}{2(1-k)},$$
(46)

which, by substituting into Equation 44, gives

T(x)

$$M(x) \begin{cases} 3k^2 M(w)^4 - 2(k-1)kM(w)^3 \\ -3k[2M(0)^2 + M(x)(k-1)]M(w)^2 + 3M(0)^4 + \\ +2(k-1)M(0)^3 + 3M(x)(k-1)M(0)^2 \\ +2M(x)^2k^2 - 4M(x)^2k + 2M(x)^2 \\ \end{cases}$$

$$= \frac{(k-1)^2}{(k-1)^2}.$$
(47)

Finally, using Equation 12, we can express the third central moment resulting from the injection of holes only (x = 0) as a function of their mean gain M(0):

T(0)

$$=\frac{3M(0)^{5}+5(k-2)M(0)^{4}+2(k^{2}-6k+6)M(0)^{3}-3(k^{2}-3k+2)M(0)^{2}+(k-1)^{2}M(0)}{k^{2}}.$$
(48)

Similarly, for electrons only (x = w), the third central moment can be expressed as a function of their mean gain M(w):

$$T(w) = 3k^{2}M(w)^{5} - 5k(2k-1)M(w)^{4} + 2(6k^{2} - 6k + 1)M(w)^{3} - -3(2k^{2} - 3k + 1)M(w)^{2} + (k^{2} - 2k + 1)M(w).$$
(49)

2.4 Impact on spectral measurements

When the initial number of electron-hole pairs starting the avalanche is also a statistical quantity, like upon the interaction of the semiconductor device with ionizing radiation such as an X-ray photon or a charged particle, the total number of generated pairs after multiplication follows the composition rules of a random sum. Let $n \in \{0, 1, 2, ...\}$ be the random variable representing the number of generated electron-hole pairs at position x within the sensor. Let $\{\mathcal{M}_i(x)\}_{i=0}^{\infty}$ be the independent and identically distributed random variables representing the multiplication gain as a consequence of one single pair starting at position x. The total signal \mathcal{P} corresponds to a random sum and can be written as $\mathcal{P}(x) = \sum_{i=0}^{n} \mathcal{M}_i(x)$.

According to Equation B1 in Appendix 1, the mean value of \mathcal{P} simply is

$$\mathbb{E}[\mathcal{P}(x)] = \mathbb{E}[n]M(x) = \frac{E_0}{\epsilon}M(x),$$
(50)

where in the last passage, we used the common relationship that the mean number of initial electron–hole pairs equals the ratio between the energy deposited in the semiconductor by the impinging particle E_0 and the material-specific average pair creation energy ϵ .

The variance of \mathcal{P} , according to Equation B2 in Appendix 2, is

$$\mathbb{V}[\mathcal{P}(x)] = \mathbb{E}[n]V(x) + M(x)^2 \mathbb{V}[n],$$
(51)

$$=\frac{E_0}{\epsilon}\left[V(x) + fM(x)^2\right],\tag{52}$$

where in the last passage, we used the common relationship that the variance of the initial number of electron–hole pairs equals its mean value scaled by an approximately constant material-specific factor f, called the Fano factor.

The third central moment of \mathcal{P} , according to Equation B3 in Appendix 3, is



Equation 49, while curves labeled with "injected holes" correspond to M(0), converted from M(w) using Equation 12 and T(0) in Equation 48.

$$\mathbb{T}[\mathcal{P}(x)] = \mathbb{E}[n]T(x) + 3M(x)V(x)\mathbb{V}[n] + M(x)^{3}\mathbb{T}[n], \quad (53)$$
$$= \frac{E_{0}}{\epsilon}[T(x) + 3fM(x)V(x)] + M(x)^{3}\mathbb{T}[n]. \quad (54)$$

The determination of the value of $\mathbb{T}[n]$ requires more careful attention. The literature on the topic is rather scarce, but in a recent work [22], it was proposed that n could be modeled as a Conway–Maxwell–Poisson distribution (CMP or COM–Poisson). Originally developed in 1960s in the framework of queuing systems with dependent service times, it generalizes the Poisson distribution by adding a parameter to model overdispersion and under-dispersion, and for a random variable X, it is defined as

$$\Pr(X = x | \lambda, \nu) = \frac{\lambda^{x}}{(x!)^{\nu} Z(\lambda, \nu)} \quad \text{for } x \in \mathbb{N}_{0}, \lambda > 0 \text{ and } \nu \ge 0,$$
(55)

where $Z(\lambda, \nu)$ is a normalizing constant:

$$Z(\lambda,\nu) = \sum_{s=0}^{\infty} \frac{\lambda^s}{(s!)^{\nu}},$$
(56)

and the parameter ν controls the dispersion of the distribution. Specifically, $\nu > 1$ will result in under-dispersion, whereas $\nu < 1$ will result in over-dispersion. In the special case of $\nu = 1$, the COM–Poisson distribution reduces to the regular Poisson distribution, and λ simply becomes the expectation value, which is in general not the case. There are no simple closed analytical forms for the statistical moments, but useful approximations are available from [23]:





$$\mathbb{E}[X] \approx \lambda^{1/\nu} - \frac{\nu - 1}{2\nu},\tag{57}$$

$$\mathbb{V}[X] \approx \frac{\lambda^{1/\nu}}{\nu},\tag{58}$$

$$\mathbb{T}[X] \approx \frac{\lambda^{1/\nu}}{\nu^2},\tag{59}$$

which are nominally accurate in the asymptotic regime when $\nu < 1$ or when $\lambda > 10^{\nu}$. The parameters λ and ν can be extracted by inverting Equations 57, 58, which in our case resolves to [22]

$$\left(\frac{E_0}{\epsilon}, f\right) \approx \frac{2\frac{E_0}{\epsilon} + 1 + \sqrt{4\frac{E_0}{\epsilon}\left(\frac{E_0}{\epsilon} + 1 - 2f\right) + 1}}{4\frac{E_0}{\epsilon}f},\tag{60}$$

$$\lambda\left(\frac{E_0}{\epsilon}, f, \nu\right) \approx \left(\frac{E_0}{\epsilon}\nu f\right)^{\nu},\tag{61}$$

which allow for the computation of $\mathbb{T}[n]$ using Equation 59. It is worth noting that, for large values of $\frac{E_0}{\epsilon}$, Equation 60 is simplified to $\nu \approx \frac{1}{f}$, and Equation 61 simplified to $\lambda \approx (\frac{E_0}{\epsilon})^{\nu}$, thus leading to the fairly simple relation³ $\mathbb{T}[n] \approx f^2 \frac{E_0}{\epsilon}$.

3 Results

ν

Figure 1 shows the behavior of the third central moment T of the multiplication gain distribution \mathcal{M} as a function of the mean value M for different values of the ratio between hole and electron ionization coefficient k. Curves labeled with "injected electrons"

³ For example, in silicon, assuming ϵ = 3.61 eV and f = 0.125, an error below 10% is obtained for $E_0 > 60$ eV.



FIGURE 3

Skewness of the distribution of the total signal ${\mathcal P}$ following the point-like interaction of an ionizing particle of energy E_0 with a silicon avalanche diode at position x = w (corresponding to the "injected electron" case), exhibiting a mean multiplication gain M and k =0.33. Skewness values of 0.5 indicate a mildly skewed distribution and 2 indicate a highly skewed distribution, which are shown for reference

correspond to M(w) and T(w) in Equation 49, whereas curves labeled with "injected holes" correspond to M(0), converted from M(w) using Equation 12, and T(0) in Equation 48. The third central moment is equal to 0 in correspondence of the minimum mean multiplication gain M = 1 and is always a positive quantity, indicating that the gain distribution is right-skewed, i.e., its tail is more pronounced on the right-hand side of the mean toward higher gain values.

Figure 2 shows the skewness S of the multiplication gain distribution \mathcal{M} , computed according to Equation 34, as a function of the mean value M and for different values of k. The curve labeling has the same meaning, as shown in Figure 1. Salient characteristics of the skewness are i) as M tends to 1, S tends to infinity; ii) S has a global minimum at positions slightly above the unity gain, depending on the value of k; and iii) S is always higher than 2, which is typically indicated as a threshold for a distribution to be considered significantly skewed [24].

Figure 3 shows, as an example, the skewness S of the distribution of the total signal \mathcal{P} , resulting from the interaction, assumed pointlike, of an ionizing particle with a silicon avalanche diode at position x = w, which corresponds to the "injected electron" case. The energy E_0 of the impinging particle is in the range 1 eV-1 keV, and the mean multiplication gain M is in the range 1–1,000. The third central moment of the total signal \mathcal{P} was computed with Equation 59, using Equations 60, 61. The pair creation energy is $\epsilon = 3.61$ eV, the Fano factor is f = 0.125, and the ionization coefficient ratio is k = 0.33. The plot includes skewness values of 0.5, indicative threshold of a mildly skewed distribution, and 2, indicative threshold of a highly skewed distribution, for reference. As shown in Figure 2, increasing values of mean multiplication gain lead to increased skewness, whereas increasing values of initial particle energy lead to decreased skewness as a consequence of the central limit theorem.

4 Conclusion

We derived exact analytical expressions for the variance, the third central moment, and the skewness of the multiplication gain in uniform avalanche structures as a function of the starting position of the electron-hole pair generating the avalanche. The expressions were obtained by solving integral equations based on the property of additivity of the central statistical moments of the sum of random variables and moment composition rules of the random sum. The assumptions include Poissonianity and locality of the ionization process. The model is valid for arbitrary values of electron and hole ionization coefficients α and β , respectively, as functions of the space coordinate. Although the variance is already known from its relationship with the excess noise in current fluctuations in stationary conditions via Milatz's theorem, this study, provides an alternative, perhaps more physically intuitive, derivation.

Expressions are then provided for the particular case where the ionization coefficients are related by a constant ratio $k = \beta/\alpha$. In this context, it is found that the third central moment increases asymptotically with the fifth power of the mean multiplication gain and that the skewness is always positive and greater than 2, which is typically indicated as a threshold for a distribution to be considered significantly skewed.

The impact of the first three central moments of the multiplication gain distribution on spectral measurements of ionizing radiation was also evaluated through the use of the composition rules for a random sum. In this framework, we adopted the COM-Poisson distribution, a generalization of the Poisson distribution which takes into account the under-dispersion effect parameterized by the Fano factor as a description of the distribution of the initial number of photogenerated electron-hole pairs.

Data availability statement

The raw data supporting the conclusions of this article will be made available by the authors, without undue reservation.

Author contributions

PZ: writing-original draft and writing-review and editing.

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Appendix

Let $k \in \{0, 1, 2, ...\}$ be a random variable, and let $\{X_i\}_{i=0}^{\infty}$ be independent identically random variables that are independent of k. The random variable $Y_k = \sum_{i=0}^k X_i$ is called a random sum.

1 Mean value of a random sum

The mean value of the random sum $\mathbb{E}[Y_k]$ is straightforwardly

$$\mathbb{E}[Y_k] = \mathbb{E}[X_0]\mathbb{E}[k]. \tag{B1}$$

2 Variance of a random sum

The variance of a random sum $\mathbb{V}[Y_k]$ is [7, 10]

$$\mathbb{V}[Y_k] = \mathbb{V}[X_0]\mathbb{E}[k] + \mathbb{E}[X_0]^2\mathbb{V}[k].$$
(B2)

3 Third central moment of a random sum

The third central moment of a random sum $\mathbb{T}[Y_k]$ is

$$\mathbb{T}[Y_k] = \mathbb{E}[k]\mathbb{T}[X_0] + \mathbb{E}[X_0]^3\mathbb{T}[k] + 3\mathbb{E}[X_0]\mathbb{V}[X_0]\mathbb{V}[k].$$
(B3)

Proof

The third central moment $\mathbb T$ of any random variable X is

$$\mathbb{T}[X] = \mathbb{E}[(X - \mathbb{E}[X])^3], \tag{B4}$$

$$= \mathbb{E}[X^3] - 3\mathbb{E}[X]\mathbb{V}[X] - \mathbb{E}[X]^3, \tag{B5}$$

which, in our case, means

$$\mathbb{T}[Y_k] = \mathbb{E}[Y_k^3] - 3\mathbb{E}[Y_k]\mathbb{V}[Y_k] - \mathbb{E}[Y_k]^3.$$
(B6)

By applying the theorem of total moment on a random sum, we can write

$$\mathbb{E}[Y_k^3] = \sum_{i=0}^{\infty} \mathbb{E}[Y_i^3 | k = i] = \sum_{i=0}^{\infty} \mathbb{E}[Y_i^3] \Pr(k = i).$$
(B7)

By inverting Equation B6, we know that for any Y_i , the following holds:

$$\mathbb{E}[Y_i^3] = \mathbb{T}[Y_i] + 3\mathbb{E}[Y_i]\mathbb{V}[Y_i] + \mathbb{E}[Y_i]^3,$$
(B8)

and from basic statistics, we also know that

$$\mathbb{E}[Y_i] = i\mathbb{E}[X_0],\tag{B9}$$

$$\mathbb{V}[Y_i] = i \mathbb{V}[X_0], \tag{B10}$$

$$\mathbb{T}[Y_i] = i\mathbb{T}[X_0],\tag{B11}$$

so that Equation B8 becomes

$$\mathbb{E}[Y_i^3] = i\mathbb{T}[X_0] + 3i^2\mathbb{E}[X_0]\mathbb{V}[X_0] + i^3\mathbb{E}[X_0],$$
(B12)

and therefore, Equation B7 can be written as

$$\mathbb{E}[Y_k^3] = \sum_{i=0}^{\infty} [i\mathbb{T}[X_0] + 3i^2 \mathbb{E}[X_0] \mathbb{V}[X_0] + i^3 \mathbb{E}[X_0]^3] \Pr(k=i),$$
(B13)

$$= \mathbb{E}[k]\mathbb{T}[X_0] + 3\mathbb{E}[k^2]\mathbb{E}[X_0]\mathbb{V}[X_0] + \mathbb{E}[k^3]\mathbb{E}[X_0]^3.$$
(B14)

By substituting Equation B14 into Equation B6 and obtaining the mean value of a random sum from Equation B1 and the variance of a random sum from Equation B2, we get

$$\mathbb{T}[Y_k] = \mathbb{E}[Y_k^3] - 3\mathbb{E}[Y_k]\mathbb{V}[Y_k] - \mathbb{E}[Y_k]^3, \qquad (B15)$$

$$= \mathbb{E}[k]\mathbb{T}[X_0] + 3\mathbb{E}[k^2]\mathbb{E}[X_0]\mathbb{V}[X_0] + \mathbb{E}[k^3]\mathbb{E}[X_0]^3$$

$$-3\mathbb{E}[k]\mathbb{E}[X_0] (\mathbb{E}[k]\mathbb{V}[X_0] + \mathbb{E}[X_0]^2\mathbb{V}[k]) - \mathbb{E}[k]^3\mathbb{E}[X_0]^3,$$

(B16)

$$= \mathbb{E}[k]\mathbb{T}[X_0] + \mathbb{E}[X_0]^3 \left(\mathbb{E}[k^3] - 3\mathbb{E}[k]\mathbb{V}[k] - \mathbb{E}[k]^3\right)$$
$$+ 3\mathbb{E}[X_0]\mathbb{V}[X_0] \left(\mathbb{E}[k^2] - \mathbb{E}[k]^2\right), \tag{B17}$$

$$= \mathbb{E}[k]\mathbb{T}[X_0] + \mathbb{E}[X_0]^3\mathbb{T}[k] + 3\mathbb{E}[X_0]\mathbb{V}[X_0]\mathbb{V}[k].$$
(B18)